

III. h. Bellows (Extension) Factor

When photographs are taken where the focus is at a point other than infinity, an exposure correction must be made. At most working distances, this correction factor is so small that it can be ignored. However, when working at very close distances, it becomes significant and can result in exposure errors if not corrected for. This exposure variation is commonly called extension factor or bellows factor.

There are several ways to correct for this effect. Two of the most commonly used take into account the lens focal length and the lens to film plane distance (bellows extension).



For example, assume an object size of 2 inches and image size of 4 inches.

$$EF = \left(\frac{d}{f}\right)^2$$

$$= \left(\frac{10}{2}\right)^2$$

$$= 25$$

Setting 9 in the EF correction ring of the Luna Pro F will correct exposures for this condition.

Extension and filter factors can be eliminated from exposure readings by using the accessory Fiber Optic Attachment and reading on the camera groundglass. The scale on the groundglass will automatically be corrected and compensated for by the meter.

The third method gives you an extension factor which can be programmed into the exposure factor ring of the Luna Pro F for direct reading of corrected exposure values. The second method gives a corrected aperture only.

$$I. \text{ Extension Factor} = \frac{(L + d)^2}{L^2}$$

(L = lens focal length)
(L + d = lens to film plane distance)

For example, assume a 35mm lens (approximately f/11) to be used with a lens to film plane distance of 14".

$$\text{Extension Factor} = \frac{(14 + 35)^2}{35^2}$$

$$= \frac{49^2}{1225}$$

$$= 1.96$$

Setting 9 in the EF correction ring of the Luna Pro F will correct exposures for this condition.

Extension and filter factors can be eliminated from exposure readings by using the accessory Fiber Optic Attachment and reading on the camera groundglass. The scale on the groundglass will automatically be corrected and compensated for by the meter.

In this case, set the white index mark of the exposure factor ring opposite the number 3. Note that the exposure factor portion of the copy numbers in black should be used, not the EV portion. All readings will now be corrected for lens extension factor.

$$II. \text{ Effective Aperture} = \frac{L}{L + d}$$

(L = lens focal length)
(L + d = lens to film plane distance)

For example, assume the same conditions as in Example I with an indicated f/11.

$$\text{Effective Aperture} = \frac{35}{14 + 35}$$

$$= \frac{35}{49}$$

$$= f/1.4$$

In this case, if the lens were set to f/11, the exposure level would be the same as if the lens were set to f/1.4, although, depth of field would remain the same as for f/11. Using this method, each time a different f/stop is chosen, the same amount of correc-

tion must be recalculated with the exposure factor ring of the Luna Pro F is much easier and more flexible because once the exposure factor is programmed, all subsequent readings are corrected for with additional calculations and in terms of all values, not just f/stops.

Another way to determine extension factor is to measure the magnification of the object size at the lens plane. This is especially useful when working with large format cameras where measurement of the image on the ground glass is relatively easy.

To calculate the extension factor, measure both the actual object size and the size of the image on the ground glass. These two measurements are used in the formula below:

$$EF = \left(\frac{\text{Image Size}}{\text{Object Size}} + 1\right)^2$$

Accessories

All of these excellent features are only the beginning of the Luna Pro F story. The wide range of instantly interchangeable accessories for the Luna Pro F distinctly apart from other light measuring instruments.

For direct reading with proper exposure values, make the following exposure corrections when using your Luna Pro F attachments with your Luna Pro F Exposure Meter.

Variable Angle Attachment
The EV+ section of the dial is used. When using the 15° position, set the index mark opposite +10 EV. When using the 7.5° position, set the index mark opposite +3EV. Readings are then taken normally.

Repro [Copy] Attachment & Fiber Optics Probe:
Set the index mark opposite +2 EV on your exposure correction dial.

Section IV

For complete instructions on how to use these and other attachments with your Luna Pro F, refer to the Luna Pro F Instruction Manual, Berkey Marketing Companies, 25-29 Bocklyn-Queens Expressway West, Woodside, New York 11377.

Enlarging Attachment

The Enlarging Attachment will help eliminate guesswork in darkroom printing. It determines contrast range and correct exposure factor. It is a 100% film. By measuring the original and the copy, the enlarger is set. After calibration for paper speed, direct readings of exposure values are possible, resulting in savings of time and material.



Microscope Attachment

The Microscope Attachment utilizes the Luna Pro F measuring sensitivity for accurate photometric measurements when taking photomicrographs. The Microscope Attachment fits the optical tube of most microscopes for exact exposure determination, and is useful in measuring light intensity for fluorescent microscopy.



Fiber Optics Probe Attachment

With the flexible Fiber Optics Probe Attachment on the Luna Pro F, measurements can be made in many areas which are usually inaccessible with an exposure meter. It is especially suitable for many photography, ground glass measurements, density measurements on negatives or transparencies, and for luminous density measurements.



Variable Angle Attachment

The recently priced Variable Angle Attachment locks instantly into the Luna Pro F and provides convenient readings at either 15° or 7.5° measuring angles. For reflected light readings, the normal measuring angle corresponds to a light acceptance angle of 15° and 7.5°.



Repro [Copy] Attachment

With the Repro Attachment on the Luna Pro F, it is possible to obtain exposure values of flat copy such as printouts, documents, and photographic prints.

The illumination on the copy board can be measured for evenness of various points on the material to be copied. It can also be reversed for measurements of light transmitted through slides or other translucent material being copied.



Section V

Appendix

ASA & DIN Values		Intermediate ASA & DIN Values		Intermediate F/stop Values	
ASA	DIN	ASA	DIN	F/stop	F/stop
0.8	5	1.0	8	2.8	11
1	6.3	1.25	10	3.2	12.5
1.25	8	1.56	12.5	3.6	14
1.56	9	2	16	4	16
2	11	2.5	20	4.5	18
2.5	12.5	3.15	25	5	20
3.15	14	4	32	5.6	22.4
4	16	5	40	6.3	25.1
5	18	6.3	50	7.1	28
6.3	20	8	64	8	32
8	25	10	80	9	36
10	32	12.5	100	10	40
12.5	40	16	128	11.2	45
16	50	20	160	12.5	50
20	63	25	200	14	56
25	80	32	256	16	64
32	100	40	320	18	72
40	125	50	400	20	80
50	160	63	500	22.4	90
63	200	80	640	25.1	100
80	250	100	800	28	112
100	320	125	1000	32	128
125	400	160	1280	36	144
160	500	200	1600	40	160
200	630	250	2000	45	180
250	800	320	2560	50	200
320	1000	400	3200	56	224
400	1250	500	4000	63	251
500	1600	630	5000	71	280
630	2000	800	6400	80	320
800	2500	1000	8000	90	360
1000	3200	1250	10000	100	400

Technical Specifications

Photo Cell	Silicon Blue Cell
Angle of Coverage	30° (Reflected 180° Incident)
Sensitivity	125 to 32,000 f/stop-candies
Power Source	916 (6-AG13) watchbatteries
Dimensions	3.10 x 1.50 x 0.75 (Type MN 1800)
Weight	0.84 oz. (with battery)
Scale Ranges:	4.5 to 144 f/stop
Exposure Values	8 to 24 EV
Shutter Speeds	1/4000 sec. to 8 hours
Apertures	f/1.4 to f/22
File Speeds	ISO (ASA) 0.8 to 100,000 to 0.1 DIN

Additional Reference Material

- Eastman Kodak Co. KODAK Publications, Rochester, New York 14650
- KODAK Professional Photo Guide R-28
- KODAK Professional Black and White Films, 2nd Ed. 7-0
- KODAK Color Films, 6th Ed. E-77
- Scientific and Image Structure Data for KODAK Color Films E-78
- Berkey Photographic Sensitometry Workbook, 222 FD
- Lens Extension Tables P-308
- KODAK Plates and Films for Scientific Photography P-315
- KODAK Films for Scientific and Technical Uses, 1st Ed. 8-3
- Brownie, Louis. *Vision Camera Techniques*. Hastings House Publishers, Inc., New York, New York 10016
- Zavis, Richard and Todd, Hollis. *Photographic Sensitometry*. Morgan and Morgan, Inc., Dobbs Ferry, New York 10522
- Sturge, John. *Handbook of Photography and Reprography Materials, Processes and Systems*. Seventh Edition. Van Nostrand Reinhold Co., New York, New York 10010
- Simsion, A. *Photometry and Radiometry for Engineers*. John Wiley & Sons, Inc., New York, New York 10015
- Dowdell, G. H. and Zavis, R. *Zone System*. Morgan and Morgan, Inc., Dobbs Ferry, New York 10522
- Saunders, Norman. *Photographic Tone Control*. Morgan and Morgan, Inc., Dobbs Ferry, New York 10522
- Clark, Phil. *Beyond the Zone System*. Curton & Long, Inc. and Van Nostrand Reinhold Co., New York, New York

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Instruction Manual

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